

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	416	(438/800).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2009/02/17 08:22
S1	3840	SINT or silicon nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:49
S2	28407172	@ad<="20040511"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:50
S3	1942	S1 and S2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:50
S4	996	S3 and ratio	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:50
S5	1385	silicon nano\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:58
S6	117	silicon nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 09:58
S7	503	(mixture or solution) near3 ((silicon oxide or silicon dioxide or "SiO.sub.2") near3 (water or solvent))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 10:45
S8	123792	nano\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 10:45
S9	20	S7 and S8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 10:45
S10	159	hydrothermal and (SINT or carbon nanotube or silicon nanotube)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:10
S11	12	hydrothermal and (SINT or silicon nanotube)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:18

S12	30828	nanotube or nanowire	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:27
S13	7	S7 and S12	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:27
S14	5733	(mixture or solution) near3 ((silicon oxide or silicon dioxide or "SiO.sub.2" or silica) near3 (water or solvent))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:29
S15	40	S14 and S12	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:30
S16	65	silica nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 11:39
S17	1310	(silica or silicon) (nanotube or nanowire) or (Si or "SiO. sub.2") (nanotube or nanowire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:17
S18	1314	(silicon dioxide or silica or silicon) (nanotube or nanowire) or (Si or "SiO. sub.2") (nanotube or nanowire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:17
S19	49275	pressure adj5 MPa	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:17
S20	10	S18 and S19	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:18
S21	10136	(mixture or solution) near5 ((silicon oxide or silicon dioxide or "SiO.sub.2" or silica) near5 (water or "H. sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:25
S22	5	S21 and S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:26
S23	75	((silica or silicon) (nanotube or nanowire) or (Si or "SiO. sub.2") (nanotube or nanowire)) same self assembl \$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 14:29

S24	9013108	(mixture or solution or suspension)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:30
S25	903	S18 and S24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:30
S26	3040272	ratio or "By" weight	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:31
S27	584	S25 and S26	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:31
S28	1960426	temperature and pressure	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:31
S29	381	S27 and S28	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:31
S30	10246	outer (diamter or radius) and (inner pore or inner (diameter or radius))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:32
S31	0	S29 and S30	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:34
S32	158790	outer (diameter or radius) and (inner pore or inner (diameter or radius))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:34
S33	10	S29 and S32	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/01 15:34
S34	11106	(mixture or solution or suspension) near5 ((silicon oxide or silicon dioxoide or "SiO.sub.2" or silica) near5 (water or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 07:41
S35	190	(silicon or Si or silica or silicon oxide or "SiO.sub.2") nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 07:43
S36	4	S34 with nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 09:14

S37	16	S34 same nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 09:15
S38	42	(977/883).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/02 09:23
S39	8	977/883	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 09:23
S40	51	(977/855).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/02 09:33
S41	18	977/855	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 09:33
S42	33	(977/848).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/02 09:44
S43	8	977/848	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 09:44
S44	29	(977/743).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/02 10:10
S45	4	S44 and closed end\$2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/02 10:44
S46	12	"6,649997"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/06 09:20
S47	12	"6649997"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/06 09:20
S48	18	977/743	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 09:41
S49	172	(977/734).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/08 09:42

S50	29	(977/743).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/08 09:42
S51	83	(977/938).OCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/10/08 09:45
S52	1	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube or SINT) with closed end	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:18
S53	12	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube or SINT) same closed end	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:19
S54	35	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube or SINT) same (closed near3 end)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:20
S55	35	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube or SINT) same ((closed or unopened) near3 end)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:21
S56	3	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube) and (silicon or Si) near3 (inner (layer or film or material) or inner wall or wall (layer or film or material) or core) and (silicon dioxide or silica or "SiO.sub.2" or silicon oxide) near3 (outer (layer or film or material) or outer wall or wall (layer or film or material) or shell)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:25
S57	3	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube) and (silicon or Si) near5 (inner (layer or film or material) or inner wall or wall (layer or film or material) or core) and (silicon dioxide or silica or "SiO.sub.2" or silicon oxide) near5 (outer (layer or film or material) or outer wall or wall (layer or film or material) or shell)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:27

S58	3	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube) and (silicon or Si) near7 (inner (layer or film or material) or inner wall or wall (layer or film or material) or core) and (silicon dioxide or silica or "SiO.sub.2" or silicon oxide) near7 (outer (layer or film or material) or outer wall or wall (layer or film or material) or shell)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:27
S59	7	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube) and (silicon or Si) with (inner (layer or film or material) or inner wall or wall (layer or film or material) or core) and (silicon dioxide or silica or "SiO.sub.2" or silicon oxide) with (outer (layer or film or material) or outer wall or wall (layer or film or material) or shell)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 10:28
S60	9	("20020117659" "20020130311" "20020175408" "20030165418" "20040005723" "20040076681" "6113722" "6613875").PN. OR ("7355216").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2008/10/08 10:31
S61	7	((silica or silicon or silicon dioxide or Si or "SiO.sub.2" or SiO2) adj2 nanotube) and (silicon or Si) with (inner (layer or film or material) or inner wall or wall (layer or film or material) or core) and (silicon dioxide or silica or "SiO.sub.2" or silicon oxide) with (outer (layer or film or material) or outer wall or wall (layer or film or material) or shell or sheath)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2008/10/08 11:02

S62	19	("20020117659" "20020130311" "20020175408" "20030165418" "20040005723" "20040175844" "20040262636" "20050024433" "20050036939" "20050053525" "20050056118" "20050101020" "5352512" "6123819" "6194066" "6221154" "6413880" "6656573" "6962823").PN. OR ("7211143").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2008/10/08 11:21
S63	0	("7132126").URPN.	USPAT	ADJ	ON	2008/10/08 11:37
S64	63	(Silicon nano\$4 or silica nano \$4 os SINT or SiNW) and (mixture or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) and (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 11:23
S65	63	(Silicon nano\$4 or silica nano \$4 os SINT or SiNW) and ((mixture or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) and (water or H2O or "H.sub.2O")))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 11:27
S66	11	(Silicon nano\$4 or silica nano \$4 os SINT or SiNW) and ((mixture or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) with (water or H2O or "H.sub.2O")))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 11:54
S67	20	(US-20040175844-\$ or US- 20020141934-\$ or US- 20060060857-\$ or US- 20030119920-\$ or US- 20060118712-\$ or US- 20050036939-\$ or US- 20020117659-\$ or US- 20020175408-\$).did. or (US- 7132126-\$ or US-7211143-\$ or US-7150840-\$ or US- 6940088-\$ or US-7276424-\$ or US-6656573-\$).did. or (JP- 2005139044-\$ or JP-	US-PGPUB; USPAT; JPO; DERWENT	ADJ	ON	2009/02/06 14:08

		2002037614-\$ or JP-2000256007-\$).did. or (JP-2005139044-\$ or JP-2007091848-\$ or KR-766748-\$).did.				
S68	18	S67 and (mixture or solution or composite or slurry or disper\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:15
S69	62	(Silicon nano\$4 or silica nano\$4 os SiNT or SiNW) and (mix\$4 or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) and (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:18
S70	193720	(mix\$4 or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) and (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:19
S71	44201	(mix\$4 or hydrothermal or solution or slurry or composite) with ((silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) near10 (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:19
S72	8253	(ratio or weight or percent\$3 adj2 weight) near5 (silicon oxide or silicon dioxide or SiO or "SiO.sub.2" or SiO2 or silica) near5 (water or H2O or "H.sub.2O")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:21
S73	5451	S71 and S72	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:21
S74	501401	temperature and pressure and stir\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:22
S75	2025	S73 and S74	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:22
S76	97	S75 and nano\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:22

S77	78	ratio adj7 (silicon oxide or "SiO.sub.2" or SiO ₂ or silica or SiO) near5 (water or H ₂ O or "H.sub.2O") adj5 (weight or percent\$4 adj2 weight)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/06 14:40
S78	20	(US-20040175844-\$ or US-20020141934-\$ or US-20060060857-\$ or US-20030119920-\$ or US-20060118712-\$ or US-20050036939-\$ or US-20020117659-\$ or US-20020175408-\$).did. or (US-7132126-\$ or US-7211143-\$ or US-7150840-\$ or US-6940088-\$ or US-7276424-\$ or US-6656573-\$).did. or (JP-2005139044-\$ or JP-2002037614-\$ or JP-2000256007-\$).did. or (JP-2005139044-\$ or JP-2007091848-\$ or KR-766748-\$).did.	US-PGPUB; USPAT; JPO; DERWENT	ADJ	ON	2009/02/09 07:41
S79	13	S78 and (silicon oxide or silicon dioxide or "SiO.sub.2" or SiO or silica or SiO ₂)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 07:42
S80	5328	Silicon nanotube or silica nanotube or SINT or SINW or silicon nanowire or silica nanowire	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:21
S81	28420138	@ad<"20040511"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:22
S82	2315	S80 and S81	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:22
S83	3988	Silicon nanotube or silica nanotube or SINT	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:22
S84	1971	S81 and S83	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:22
S85	4967753	(water or "H.sub.2O" or H ₂ O)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:23
S86	1193	S82 and S85	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:23

S87	200359	(mix\$4 or disper\$4 or solution or suspension or composite) with ((silicon oxide or SiO or silicon dioxide or "SiO.sub.2" or silica) and (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:35
S88	25789	(mix\$4 or disper\$4 or solution or suspension or composite) with ((silicon oxide or SiO or silicon dioxide or "SiO.sub.2" or silica) near5 (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:36
S89	15117	(mix\$4 or disper\$4 or solution or suspension or composite) with ((silicon oxide or SiO or silicon dioxide or "SiO.sub.2" or silica) near3 (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:37
S90	101	S89 and nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 08:37
S91	34358	(mix\$4 or disper\$4 or solution or suspension or composite) with ((silicon oxide or SiO or silicon dioxide or "SiO.sub.2" or silica) near7 (water or H2O or "H.sub.2O"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:19
S92	28	S91 same (nanotube or nanowire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:20
S93	2	(silicon or silica) nanotube with hydrothermal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:32
S94	5	(silicon or silica) nanotube and hydrothermal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:32
S95	15	(SiNT or (silicon or silica) nanotube) and hydrothermal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:33
S96	3819	ratio with (("SiO.sub.2" or SiO or silicon oxide or silicon dioxide or silica) near5 ("H.sub.2O" or H2O or water))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:51
S97	265	S96 same (temperature and stir\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:52

S98	277	S96 same ((temperature or calcin\$5) and stir\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:52
S99	3819	ratio with (("SiO.sub.2" or SiO or silicon oxide or silicon dioxido or silica) near5 ("H.sub.2O" or H2O or water))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:54
S100	277	S99 same ((temperature or calcin\$5) and stir\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/09 09:54
S101	17278	(mix\$4 or solution or composite or slurry or suspension or dispers\$3) with ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) near3 (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:48
S102	4468	(mix\$4 or solution or composite or slurry or suspension or dispers\$3) with ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) near (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:49
S103	9238	(mix\$4 or solution or composite or slurry or suspension or dispers\$3) near3 ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) near3 (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:49
S104	927	(mix\$4 or solution or composite or slurry or suspension or dispers\$3) near ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) near (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:50
S105	335544	stir\$3 near4 (hour or minute)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:50
S106	424621	stir\$4 near4 (hour or minute)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:51
S107	927	S103 and S104	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:51

S108	1916	S103 and S106	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:51
S109	616512	temperature near5 ("100" or "150" or "200" or "250" or "300" or "350" or "400" or "450" or "500")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 14:52
S110	615	S108 and S109	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 15:09
S111	1260	ratio with ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) near (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 15:09
S112	40	S110 and S111	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 15:10
S113	1841	ratio with ((silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) adj3 (water or "H.sub.2O" or H2O))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 15:22
S114	14	S113 and nanotube	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 15:22
S115	1	((YUANHONG) near2 (TANG)).INV.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/02/11 16:07
S116	0	((LIZHAI) near2 (PEI)).INV.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/02/11 16:07
S117	0	((YANGWEN) near2 (CHEN)). INV.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/02/11 16:08
S118	7	((CHI) near2 (GUO)).INV.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/02/11 16:08
S119	13	(hunan near2 university).as.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 16:09
S120	22835	((Silicon oxide or silicon dioxide or SiO or SiO2 or "SiO.sub.2" or silica) and (mix \$4 or solution or suspension or composite or slurry or dispers\$4) and (water or "H. sub.2O" or H2O)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 16:15

S121	999	((Silicon oxide or silicon dioxide or SiO or SiO ₂ or "SiO.sub.2" or silica) and (mix \$4 or solution or suspension or composite or slurry or dispers\$4) and (water or "H.sub.2O" or H ₂ O) and (stir \$4)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 16:15
S122	222	((Silicon oxide or silicon dioxide or SiO or SiO ₂ or "SiO.sub.2" or silica) and (mix \$4 or solution or suspension or composite or slurry or dispers\$4) and (water or "H.sub.2O" or H ₂ O) and (stir\$4) and (temperature) and (pressure)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 16:16
S123	434	((Silicon oxide or silicon dioxide or SiO or SiO ₂ or "SiO.sub.2" or silica) and (mix \$4 or solution or suspension or composite or slurry or dispers\$4) and (water or "H.sub.2O" or H ₂ O) and (stir\$4) and (ratio)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	ADJ	ON	2009/02/11 16:39

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